

# TITLE OF THE INVENTION

LIQUID CRYSTAL DISPLAY DEVICE USING A HOLOGRAM,  
HOLOGRAM SCATTER PLATE, AND PROCESS OF FABRICATING  
A DIFFUSE REFLECTION TYPE HOLOGRAM

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## BACKGROUND OF THE INVENTION

The present invention relates generally to a liquid crystal display device, and more specifically to a liquid crystal display device using a hologram diffuse plate. The present invention is also concerned with a hologram scatter plate used for liquid crystal display devices, etc., and a process of replicating a such a diffuse reflection type hologram.

Referring here to a direct-view type of liquid crystal display device, a scatter plate 12 is generally located on the side of a liquid crystal display element 20 opposite to a backlight 11 to diffuse light emanating therefrom, as shown in Figure 18, thereby widening a range capable of viewing an image displayed thereon (a visual field range).

A problem with this system is, however, that the efficiency of utilization of light is not high due to the use of a general scatter plate formed of frosted glass, and the angle of field is limited as well. The angle of field may be made wide by use of a plurality of scatter plates, but this offers a problem or gives rise to some considerable luminance drop.

A self-luminous type backlight consumes very large power, and brings about some considerable battery driving time reduction when used with laptop type computers, etc.

SUMMARY OF THE INVENTION

*Sub. a3*  
In view of such problems associated with the prior art,  
an object of the present invention is to provide a liquid  
crystal display device which has a wide visual field range  
5 and is reduced in terms of luminance drops, so that bright  
displayed images can be presented.

Another object of the present invention is to provide a  
liquid crystal display device which uses a diffuse reflection  
type hologram for backlighting so that bright displays can be  
10 presented in the light without recourse to any self-luminous  
backlight. Yet another object of the present invention is to  
provide a liquid crystal display device which can be used in  
combination with a self-luminous type backlight, so that  
battery driving time can be extended by putting off the self-  
15 luminous type backlight or using the self-luminous type  
backlight at a reduced luminance.

A further object of the present invention is to provide  
a hologram scatter plate enabling bright displayed images to  
be presented over a wide range of wavelength region and  
20 viewing angle hardly achievable with conventional hologram  
systems.

A still further object of the present invention is to  
provide a process of fabricating, by replication, a large  
diffuse reflection type hologram without joints or recorded  
25 joints, which is compatible with increased size and improved  
quality in connection with backlights, projector screens,  
combiners, etc. for liquid crystal display devices.

To accomplish the aforesaid objects, the present invention provides a liquid crystal display device using a hologram, characterized in that a liquid crystal display element is provided on a display surface side thereof with a  
5 diffuse transmission type hologram capable of diffusing and transmitting light incident from a specific direction only in a direction defined as a viewing region.

In this case, a scatter plate may be located between the liquid crystal display element and a backlight.

10 The present invention also provides a liquid crystal display device using a hologram, characterized in that between a liquid crystal display element and a backlight there is located a diffuse transmission type hologram capable of diffusing and transmitting light incident from a specific  
15 direction only in a direction defined as a viewing region.

In these cases, it is desired that the diffuse transmission type hologram has a property of diffusing and transmitting light only in a direction defined as a viewing region within a plurality of wavelength regions of different  
20 colors.

Further, the present invention provides a liquid crystal display device using a hologram, characterized in that a liquid crystal display element is provided on a back surface side thereof opposite to a display surface side thereof with  
25 a diffuse reflection type hologram capable of diffusing and reflecting light incident from a specific direction only in a direction defined as a viewing region.

In this case, a diffuse reflection plate or a reflector plate may be located on the back surface side of the diffuse reflection type hologram.

When a TN liquid crystal cell is used as the liquid crystal display element, the diffuse reflection type hologram enables diffuse reflection to occur within a range wherein the contrast of the liquid crystal cell is at least 2. When an STN liquid crystal cell is used as the liquid crystal display element, the diffuse reflection type hologram enables diffuse reflection to occur within a range wherein the contrast of the liquid crystal cell is at least 2.

More illustratively, when a TN liquid crystal cell is used as the liquid crystal display element, it is desired that the diffuse reflection type hologram enable light incident thereon from above and at an angle of about  $20^\circ$  with respect to a normal line thereof to be diffused and reflected within a range defined by an upward angle about  $10^\circ$ , a downward angle of about  $40^\circ$ , and breadth-wise angles of about  $60^\circ$ . When an STN liquid crystal cell is used as the liquid crystal display element, it is desired that the diffuse reflection type hologram enable light incident thereon from above and at an angle of about  $20^\circ$  with respect to a normal line thereof to be diffused and reflected within a range defined by an upward angle about  $20^\circ$ , a downward angle of about  $30^\circ$ , and breadth-wise angles of about  $30^\circ$ .

A self-luminous type backlight unit may be located on the back surface side of the diffuse reflection type hologram.

To accomplish the aforesaid objects, the present invention provides a hologram scatter plate which reflects incident light in a direction different from a direct reflection direction thereof, characterized in that a transmission type hologram layer and a back side layer are stacked together in the described order as viewed from an incident side thereof.

10 In accordance with this aspect, there are three cases where the transmission type hologram layer has both diffusion function and diffraction function while the back side layer is a mirror reflection layer; the transmission type hologram layer has diffraction function while the back side layer has diffuse reflection function; and the transmission type  
15 hologram layer both diffusion function and diffraction function while the back side layer has diffuse reflection function.

The transmission type hologram layer used may have diffraction function, or diffusion function and diffraction function, with respect to a plurality of different  
20 wavelengths.

The present invention also includes a liquid crystal display device having any one of the aforesaid hologram scatter plates located on a back surface side of a liquid crystal display element.

25 To accomplish the aforesaid objects, the present invention further provides a diffuse reflection type hologram replication process, characterized in that while a photosensitive material film is slid on a fixed diffuse

reflection type hologram plate in contact relation thereto, the hologram plate is irradiated from the photosensitive material film with a light beam of linear shape in section that becomes wide in a widthwise direction of the film, so  
5 that a diffuse reflection type hologram can be continuously recorded in the photosensitive material film by interference of the incident light beam with a light beam reflected and diffracted by the diffuse reflection type hologram plate.

In this case, it is preferable that the diffuse  
10 reflection type hologram plate is fixed on the surface of a transparent rod-like member rounded at at least both edges thereof. Such a transparent rod-like member may be exemplified by a semicylindrical member.

It is also desired that a combined index matching and  
15 lubricating liquid be contained between the diffuse reflection type hologram plate and the photosensitive material film.

The light beam of linear shape in section used may be exemplified by a light beam that diverges in its linear  
20 direction alone.

According to one inventive liquid crystal display device using a hologram wherein on a display surface side of a liquid crystal display element or between a liquid crystal display element and a backlight there is provided a diffuse  
25 transmission type hologram capable of diffusing and transmitting light incident from a specific direction only in a direction defined as a viewing region, it is possible to make wide a visual field region where displayed images can be

observed and reduce luminance drops, so that bright displayed images can be presented.

According to another inventive liquid crystal display device using a hologram wherein on a back surface side of a liquid crystal display element opposite to a display surface side thereof there is provided a diffuse reflection type hologram capable of diffusing and reflecting light incident from a specific direction only in a direction defined as a viewing region as mentioned above, it is possible to present bright displays in the light without recourse to any self-luminous type backlight.

According to the inventive hologram scatter plate wherein a transmission type hologram layer and a back side layer are stacked together in the described order, it is possible to limit the direction of diffraction and scattering by means of the transmission hologram and increase reflectance over a wide wavelength region by means of the back side layer, so that diffused light having high luminance can be obtained over a wide wavelength and viewing angle range, so making bright displays, etc. possible.

According to the inventive diffuse reflection type hologram replication process wherein while a photosensitive material film is slid on a fixed diffuse reflection type hologram plate in contact relation thereto, the hologram plate is irradiated from the photosensitive material film with a light beam of linear shape in section that becomes wide in a widthwise direction of the film, so that a diffuse reflection type hologram can be continuously recorded in the

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photosensitive material film by interference of the incident light beam with a light beam reflected and diffracted by the diffuse reflection type hologram plate, it is possible to easily fabricate, with no need of using any large hologram plate, a large yet continuous film form of diffuse reflection type hologram without joints or recorded joints, which has high reflectance and quality, and so is best suited for use with backlights, projector screens, combiners, etc. for liquid crystal display devices.

Still other objects and advantages of the invention will in part be obvious and will in part be apparent from the specification.

The invention accordingly comprises the features of construction, combinations of elements, and arrangement of parts which will be exemplified in the construction hereinafter set forth, and the scope of the invention will be indicated in the claims.

#### BRIEF DESCRIPTION OF THE DRAWINGS

Figure 1 is a sectional schematic of one embodiment of the liquid crystal display device according to the present invention.

Figure 2 illustrates one optical layout for recording a hologram scatter plate by a single-step exposure technique.

Figure 3 illustrates another optical layout for recording a hologram scatter plate by the single-step exposure technique.



Figure 4 illustrates yet another optical layout for recording a hologram scatter plate by the single-step exposure technique.

5 Figure 5 illustrates an optical layout for recording a hologram scatter plate by a two-step exposure technique.

Figure 6 is a sectional schematic of one embodiment of the inventive liquid crystal display device using a diffuse reflection type hologram.

10 Figure 7 is a sectional schematic of another embodiment of the inventive liquid crystal display device.

Figure 8 illustrates an optical layout for recording an intermediate hologram for the fabrication of a diffuse reflection type hologram.

15 Figure 9 illustrates an optical layout for recording a diffuse reflection type hologram using the intermediate hologram.

Figure 10 illustrates one exemplary layer structure of a diffuse reflection type hologram plate and an optical layout for replication from the same.

20 Figure 11 illustrates schematically the construction and action of the hologram scatter plate according to the present invention.

Figure 12 illustrates a method of recording one transmission type hologram used in the present invention.

25 Figure 13 illustrates a method of recording another transmission type hologram used in the present invention.

Figure 14 illustrates a layout for carrying out the replication process of a diffuse reflection type hologram according to the present invention.

Figure 15 illustrates how to assemble a hologram plate support used in the layout shown in Figure 1.

Figure 16 illustrates how to make a diffuse reflection type hologram plate by means of the single-step holography technique.

Figure 17 illustrates how to make a diffuse reflection type hologram plate by means of the two-step holography technique.

Figure 18 is a sectional schematic of a conventional liquid crystal display device.

Figure 19 illustrates a conventional layout for making a diffuse reflection type hologram by a replication technique.

#### DESCRIPTION OF THE PREFERRED EMBODIMENTS

Embodiments of the inventive liquid crystal display device using a hologram, the inventive hologram scatter plate and the inventive process of fabricating a diffuse reflection type hologram will now be explained.

Figure 1 is a sectional schematic showing one embodiment of the liquid crystal display device according to the present invention, which is similar to a conventional device shown in Figure 6 in that a backlight 11, a scatter plate 12 and a liquid crystal display element 20 are located in the described order, as viewed from the side of the backlight 11. According to the present invention, a transmission type of

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have been removed from the layout shown in Figure 1 or, alternatively, the hologram scatter plate 13 may be located between the backlight 11 and the liquid crystal element 20.

How to make the transmission type of hologram scatter plate 13 used in the instant embodiment by means of holography will now be explained.

The visual field range of a liquid crystal display device is dependent on the angle of diffusion of the hologram scatter plate 13, and the smaller the angle of diffusion, the more difficult it is to look at a displayed image. To eliminate this problem, a hologram is recorded in a desired preset visual field range only where scattering and diffraction take place.

- Single-Step Exposure -

Figure 2 is a schematic illustrative of a holographic layout designed to set a visual field (range) in the vertical direction of the hologram scatter plate 13. A scatter plate 2 is irradiated with laser light 3 from its back side to define scattered light as object light and transmitted light without being scattered as reference light 4, which are then allowed to interfere with each other in a hologram dry plate 1 for recording, thereby making the hologram scatter plate 13. In this case, the scatter plate 2 must be larger than the hologram dry plate 1, because the visual field region (range) of the hologram scatter plate 13 located at the position of the hologram dry plate 1 is then defined by the region of the scatter plate 2.

Figure 3 is again a schematic illustrative of a holographic layout designed to set a visual field (range) in the vertical direction of the hologram scatter plate 13. A scatter plate 2 is irradiated with laser light 3 from its back side to define scattered light as object light and light incident via a half mirror located between the scatter plate 2 and a hologram dry plate 1 as reference light 4, which are then allowed to interfere with each other in the hologram dry plate 1 for recording, thereby making the hologram scatter plate 13. In this case, too, the scatter plate 2 must be larger than the hologram dry plate 1, because the visual field region (range) of the hologram scatter plate 13 located at the position of the hologram dry plate 1 is defined by the region of the scatter plate 2. The layout shown in Figure 3 is advantageous over the layout shown in Figure 2 because it is easier to regulate the light quantity ratio between object light and reference light, and increase the parallelism of reference light 4.

Figure 4 is a schematic illustrative of a holographic layout designed to determine a visual field in an oblique direction with respect to a hologram scatter plate 3. One or more scatter plates 2, 2' are located at an off-axis position with respect to a hologram dry plate 1. The scatter plates 2 and 2' are then irradiated with laser light 3 and laser light 3' from their back sides, from which scattered light or object light is obliquely incident on the hologram dry plate 1 and reference light 4 is straightforward incident on the hologram dry plate 1. The object light and reference light

are then allowed to interfere with each other in the hologram dry plate 1 for recording, thereby making the hologram scatter plate 13. In this case, too, the scatter plates 2 and 2' must be larger than the hologram dry plate 1, because the visual field region (range) of the hologram scatter plate 13 located at the position of the hologram dry plate 1 is defined by the regions of the scatter plates 2 and 2'. In the layout shown in Figure 4, exposure is done with the concurrently located scatter plates 2, 2'. It is to be understood, however, that recording may be carried out by means of multi-exposure while the scatter plates 2, 2' are located at a given time interval.

- Two-Step Exposure -

According to this process, an intermediate hologram H1 is first recorded, and the thus recorded intermediate hologram H1 is then used to record a hologram scatter plate 13 that is the end hologram H2. As shown in Figure 5(a), a scatter plate 2 located in opposition to a hologram dry plate 1 for the intermediate hologram H1 is irradiated with laser light 3 from its back side, from which scattered light or object light is incident on the hologram dry plate 1 and, at the same time, reference light 4 is obliquely incident on the hologram dry plate 1. Both object light and reference light are allowed to interfere with each other in the hologram dry plate 1 to record the intermediate hologram H1.

As shown in Figure 5(b), the aforesaid intermediate hologram H1 is then used to allow the reconstructing scattered light and reference light to interfere with each

other in a hologram dry plate 1' for the end hologram H2 to record the hologram scatter plate 13. In this case, the region of the intermediate hologram H1 with respect to the hologram dry plate 1' defines the visual field region (range) of the hologram scatter plate 13 located at the position of the hologram dry plate 1'. Recording is carried out by irradiating the intermediate hologram H1 using, as reconstructing illumination light, light 4' that is conjugate with respect to reference light 4 used for recording the intermediate hologram H1. The thus scattered light or object light is incident on the hologram dry plate 1' simultaneously with the straightforward incidence of reference light 4" thereon, so that both object light and reference light can interfere with each other in the hologram dry plate 1' to obtain the end hologram scatter plate 13. It is here to be noted that, as is the case with the aforesaid single-step exposure, three processes may be envisaged for reference light 4" for making the end hologram H2 (Figures 2 to 4).

Illustrative examples of recording the hologram scatter plate 13 as shown in Figures 2 to 5 will now be explained.

#### Illustrative Example 1

A hologram photosensitive material (Omnidex 352 made by Du Pont) was applied on a glass substrate to form the hologram dry plate 1. Using the optical system shown in Figure 2, hologram recording was carried out under the following conditions:

Size of scatter plate 2: 60 cm x 80 cm

Size of hologram dry plate 1: 6 cm x 8 cm

Distance between scatter plate 2 and dry plate 1: 30 cm

Laser light 3, 4: 514.5 nm wavelength (argon laser)

Exposure: 60 mJ/cm<sup>2</sup> (at an intensity of 1 mW/cm<sup>2</sup>)

Intensity ratio between object light and reference light 4:

5 approximately 1:1

The hologram recorded under such conditions was irradiated with ultraviolet radiation at 100 mJ/cm<sup>2</sup>, and then heated at 120°C for 2 hours to obtain a hologram scatter plate having a visual field in one prescribed direction and capable of achieving bright scattering.

Illustrative Example 2

A hologram photosensitive material (Omnidex 706 made by Du Pont) was applied on a glass substrate to form the hologram dry plate 1. Using the optical system shown in Figure 3, hologram recording was carried out under the following conditions:

Size of scatter plate 2: 60 cm x 80 cm

Size of hologram dry plate 1: 6 cm x 8 cm

Distance between scatter plate 2 and dry plate 1: 30 cm

20 Laser light 3, 4: 457 nm wavelength (argon laser: B)

: 550 nm wavelength (dye laser: G)

: 647 nm wavelength (krypton laser: R)

Reference light 4: Vertical incidence/parallel light turned back by half-mirror 5

25 Object light: Vertical incidence/light scattered by scatter plate 2

Exposure: 60 mJ/cm<sup>2</sup> (exposure ratio between R, G and B:

3:2:1) (at an intensity of 1 mW/cm<sup>2</sup>)



Intensity ratio between object light and reference light 4:  
approximately 1:1

The hologram recorded under such conditions was irradiated with ultraviolet radiation at  $100 \text{ mJ/cm}^2$ , and then heated at  $120^\circ\text{C}$  for 2 hours to obtain a hologram scatter plate having a visual field in one prescribed direction and capable of achieving bright yet white scattering.

Illustrative Example 3

A hologram photosensitive material (Omnidex 352 made by Du Pont) was applied on a glass substrate to form the hologram dry plate 1. Using the optical system shown in Figure 4, hologram multi-recording was carried out under the following conditions:

Size of scatter plates 2, 2':  $60 \text{ cm} \times 80 \text{ cm}$

Size of hologram dry plate 1:  $6 \text{ cm} \times 8 \text{ cm}$

Distance between scatter plates 2, 2' and dry plate 1:  $50 \text{ cm}$

Laser light 3, 4:  $514.5 \text{ nm}$  wavelength (argon laser)

Reference light 4: Vertical incidence/parallel light

Object light (first incidence): Incidence at  $+30^\circ$ /light

scattered by scatter plate 2

Object light (second incidence): Incidence at  $-30^\circ$ /light

scattered by scatter plate 2'

Exposure: First exposure at  $5 \text{ mJ/cm}^2$

Second exposure at  $15 \text{ mJ/cm}^2$

(both at an intensity of  $1 \text{ mW/cm}^2$ )

The hologram recorded under such conditions was irradiated with ultraviolet radiation at  $100 \text{ mJ/cm}^2$ , and then heated at  $120^\circ\text{C}$  for 2 hours to obtain a hologram scatter

plate having a visual field in two prescribed directions and capable of achieving bright scattering.

Illustrative Example 4

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5 A hologram photosensitive material (8E56 made by AGFA) was applied on a glass substrate to form a hologram dry plate. Using the optical system shown in Figure 5(a), the intermediate hologram H1 was recorded under the following conditions:

Size of scatter plate 2: 6 cm x 8 cm

10 Size of hologram dry plate 1: 60 cm x 80 cm

Distance between scatter plate 2 and dry plate 2: 30 cm

Laser light 3, 4: 514.5 nm wavelength (argon laser)

Reference light 4: Incidence at 40°/parallel light

Object light: Vertical incidence/light scattered by scatter  
15 plate 2

Exposure: 150  $\mu\text{J}/\text{cm}^2$  (at an intensity of 1  $\text{mW}/\text{cm}^2$ )

Intensity ratio between object light and reference light 4:

approximately 1:1

20 Then, a hologram photosensitive material (Omnidex 352 made by Du Pont) was applied on a glass substrate to form the hologram dry plate 1'. Using the optical system shown in Figure 5(b), the end hologram H2 was recorded under the following conditions:

Size of intermediate hologram H1: 60 cm x 80 cm

25 Size of hologram dry plate 1': 6 cm x 8 cm

Distance between intermediate hologram H1 and hologram dry plate 1': 30 cm

Laser light 4', 4'': 514.5 nm wavelength (argon laser)

Reference light 4": Vertical incidence/parallel light

Object light: Incidence at 40°/light reconstructed from  
intermediate hologram H1

Exposure: 60 mJ/cm<sup>2</sup> (at an intensity of 1 mW/cm<sup>2</sup>)

- 5 Intensity ratio between object light and reference light 4":  
approximately 1:1

The hologram recorded under such conditions was  
irradiated with ultraviolet radiation at 100 mJ/cm<sup>2</sup>, and then  
heated at 120°C for 2 hours to obtain a hologram scatter  
10 plate having a visual field in one prescribed direction and  
capable of achieving bright scattering.

Another embodiment of the inventive liquid crystal  
display device using a hologram will now be explained.

According to the principle of this embodiment wherein  
15 the diffusion range of a diffuse reflection type hologram  
used as a backlight is in alignment with a practical viewing  
range of the liquid crystal display device, it is possible to  
achieve bright displays without making narrow the viewing  
region that the liquid crystal display device has.

- 20 Reference is first made to a diffuse reflection type  
hologram designed such that light incident thereon from a  
specific direction is diffused and reflected in only a  
direction defining a viewing region. A hologram having  
scatter function is known as a Lippmann hologram using a  
25 scatter plate in the form of a subject from an article  
entitled "Holographic and Interferometric Viewing Screens"  
(by Dietrich Meyerhofer, APPLIED OPTICS/Vol. 12, No.  
9/September 1973), United States Patent No. 5,046,793, etc.

To limit the viewing region of the diffuse reflection type hologram used in the present invention, processes ordinarily used for Lippmann holograms are used.

To make the diffuse reflection type hologram, a subject  
5 or diffuse plate 42 formed of frosted glass is assumed to be located at a position where a backlight forming a part of a liquid crystal display device is to be located, as shown in Figure 8. A transmission type of hologram dry plate 45 is then located at a position to define a practical viewing  
10 region, whereupon the scatter plate 42 is illuminated from its back side with one coherent light 41 of given wavelength obtained by halving light emanating from the same light source, so that scattered light 43 leaving the front side of the scatter plate 42 or object light can be incident on the  
15 transmission type of hologram dry plate 45. At the same time, another coherent light of given wavelength emanating from the same light source or reference light 44 is incident on the dry plate 45 at a given angle from the same side as the scatter plate 43. In this way, a first hologram or  
20 transmission type hologram is recorded on the transmission type of hologram dry plate 45.

Then, the first hologram, shown at 47 in Figure 9, is located at the position of the former transmission type of hologram dry plate 45, and a reflection type of hologram dry  
25 plate 50 formed of photopolymer as an example (Lippmann hologram dry plate) is now located at the position of the scatter plate 42, as shown in Figure 9. The hologram 47 is then irradiated with reconstructing illumination light 46

that is opposite in the direction of propagation to, and the same in wavelength as, the recording reference light 44, so that diffracted light 48 from the hologram 47 or object light can be incident on the reflection type of hologram dry plate 50. On the other hand, reference light 49 that propagates opposite to incident light assumed to be used with the liquid crystal display device is incident on the opposite side of the reflection type of hologram dry plate 50. In this way, a second hologram or reflection type hologram is recorded on the reflection type of hologram dry plate 50.

By use of this process it is possible to make the diffuse reflection type hologram with its viewing region limited to the range of the first hologram 47. A hologram obtained from this hologram plate by contact replication, too, may be used as a diffuse reflection type hologram in which the direction of diffraction (scattering) of the plate is kept intact.

More illustratively, the scatter plate 42 and reflection type of hologram dry plate 50 are each 155 mm in height and 205 mm in breadth, and the transmission type of hologram dry plate 45 (the first hologram 47) is 280 mm in height and 350 mm in breadth. While the reflection type of hologram dry plate 50 is spaced 300 mm away from, and inclined at an angle of  $5^\circ$  with, the scatter plate 42, the reference light 49 is incident on the reflection type of hologram dry plate 50 at a downward angle of  $20^\circ$  with respect to the normal line thereof, so that the light incident at an angle of about  $20^\circ$  from above can be uniformly diffused and reflected within a

range defined by an upward angle of about  $20^\circ$ , a downward angle of about  $30^\circ$  and breadth-wise angles of about  $30^\circ$ . This range is in substantial coincidence with a viewing range of an STN liquid crystal display element wherein a contrast of at least 2 is obtainable. It should be here understood that by making modification to the recording layout it is possible to bring that range in substantial coincidence with a viewing range of a TN liquid crystal display element wherein a contrast of at least 2 is obtainable. In this case, light incident at an angle of about  $20^\circ$  from above is permitted to be uniformly diffused and reflected within a range defined by an upward angle of about  $10^\circ$ , a downward angle of about  $40^\circ$  and breadth-wise angles of about  $60^\circ$ .

In this connection, it is to be noted that in the process of making such a diffuse reflection type hologram as mentioned above, its optical properties may often vary due to its swelling and shrinkage although depending on the hologram photosensitive material used. However, such variations can be compensated for by making correction for recording angle and selecting recording wavelength while taking the inclination, and spacing variation of interference fringes into account.

By increasing the half bandwidth of diffraction wavelength by allowing the hologram to have a multilayer structure, or contact heating (JP-A-3-46687) of color tuning film wherein monomers, plasticizers or the like are diffused into a Lippmann hologram dry plate formed of photopolymer as an example for diffraction wavelength control, it is also

possible to increase the quantity of diffused and reflected light and, hence, enhance the luminance of displays. By using a plurality of different wavelengths for one or more layers it is further possible to achieve full-color displays.

5 As shown in section in Figure 6, a diffuse reflection  
type hologram 31 obtained as mentioned above is located on  
the backlight side of a liquid crystal display device 20,  
thereby making it possible to construct a liquid crystal  
display device in which illumination light 32 incident from  
10 the display side of the liquid crystal display element 20 is  
diffused and reflected only within an angle range  $\theta$  coincident  
with the viewing region of the liquid crystal display device  
to present bright displays even in the light without recourse  
to any self-luminous type backlight. The liquid crystal  
15 display element 20 used herein, for instance, comprises a  
twisted nematic or other liquid crystal layer 25 sandwiched  
between two glass substrates 21 and 22, one glass substrate  
22 having a uniform opposite electrode 24 on its inner  
surface and the other glass substrate 21 having on its inner  
20 surface independent display electrodes 23 for each liquid  
crystal cell (R, G, B), and a color filter and a black  
matrix, although not illustrated. The electrodes 23 and 24  
are also provided with orientation layers on their sides  
opposite to the liquid crystal layer, although again not  
25 illustrated. Further, the glass substrate 21 is provided  
with a polarizing plate 26 on its outer surface while the  
glass substrate 22 located on the viewing side is provided  
with a polarizing plate 27 on its outer surface, with their

transmission axes perpendicular to one another, for instance. Voltage applied between the transparent display electrodes of the liquid crystal display element 20 is controlled per pixel to change the state of transmission, thereby displaying color  
5 images. It is here to noted that by providing a diffuse reflection plate or reflector plate on the back side of the diffuse reflection type hologram 31 in the layout shown in Figure 6, it is possible to achieve great luminance improvements.

By taking advantage of a reflection type hologram capable of diffracting a specific wavelength alone and transmitting light in other wavelength region, it is possible to set up an arrangement wherein a self-luminous type backlight 34 is located in combination with the back side of  
10 a diffuse reflection type hologram 31, as shown in Figure 7. According to this arrangement the self-luminous type backlight 34 can be used to illuminate the hologram 31 with light 35 therefrom when the liquid crystal display device is  
15 used in a dark place. When the liquid crystal display device is used in the light, the self-luminous type backlight 34 is used at a reduced luminance or put off, so that the hologram 31 can be illuminated with diffused and reflected light 33 of extraneous light 32. It is thus possible to extend the  
20 battery driving time of a portable computer or the like, with  
25 which a liquid crystal display device is used.

One example of how to make the diffuse reflection type hologram 31 will now be explained. This diffuse reflection



type hologram is to backlight an STN liquid crystal display element.

#### Recording of Transmission Type Hologram Plate

Using the layout shown in Figure 8 under the following  
5 conditions, one transmission type hologram is recorded for each wavelength, three such holograms in all.

Recording wavelength: 476.5 nm (Ar laser), 576 nm (Ar laser +  
Dye laser), and 647.1 nm (Kr laser)

Photosensitive material: 8E56 made by AGFA (476.5 nm, 576 nm)  
10 used : 8E76 made by AGFA (647.1 nm)

Exposure: 300  $\mu\text{m}/\text{cm}^2$  (476.5 nm, 647.1 nm)  
500  $\mu\text{m}/\text{cm}^2$  (576 nm)

#### Recording of Reflection Type Hologram Plate

The aforesaid three transmission type holograms are used  
15 in the optical layout shown in Figure 9 to record holograms of respective wavelengths on a single-layer dry plate formed of each of the following three photosensitive material films.

Recording wavelength: 476.5 nm (Ar laser), 576 nm (Ar laser +  
Dye laser), and 647.1 nm (Kr laser)

20 Photosensitive : HRF750X180 (647.1 nm) made by Du Pont

material used : HRF750X181 (576 nm) made by Du Pont

: HRF750X182 (476.5 nm) made by Du Pont

Exposure: 30  $\text{mJ}/\text{cm}^2$  per exposure

After this, layer stacking is carried out by post-  
25 recording treatments, viz., irradiation with UV at 200  $\text{mJ}/\text{cm}^2$  and a 2-hour heating at 120°C, as shown in Figure 10. That is, a layer structure is obtained, which is made up of 1t glass (of 1 mm in thickness), optical adhesive U-471 (made by

Kyouritsu Kagaku Co., Ltd), three hologram film layers (HRF750X180, HRF750X181, HRF750X182), 4t glass (of 4 mm in thickness), optical adhesive U-471 (made by Kyoritsu Kagaku Co., Ltd.), and ND (neutral density) glass NG (of 4 mm in thickness and 1% in transmittance, and made by Shot).

Replication of Reflection Type Hologram Plate

As shown in Figure 10, while a photosensitive film is brought into close contact with the 1t glass (of 1 mm in thickness) side of the aforesaid reflection type hologram used as a plate, recording light including three wavelengths is concurrently or successively incident on the photosensitive film to cause interference of diffracted light from the hologram layer with the incident light in the photosensitive film for replication.

Recording wavelength: 476.5 nm (Ar laser), 576 nm (Ar laser + Dye laser), and 647.1 nm (Kr laser)

Photosensitive material used: HRF700X71-20 made by Du Pont

Exposure: 30 mJ/cm<sup>2</sup> per exposure

Following this, post-recording treatments, viz., irradiation with UV at 200 mJ/cm<sup>2</sup> and a 2-hour heating at 120°C are carried out to obtain the following layer structure.

Layer Structure of Back Side Plate of Liquid Crystal Display

In order from the liquid crystal side:

Polarizing plate (LL-(82)-18 made by Sunlit Co., Ltd.):

27 (Figs. 1 & 2)

Adhesive layer (HJ-9150W made by Nitto Denko Co., Ltd.)

Hologram

Color tuning film (GA2-RED made by Du Pont)

Adhesive layer (HJ-9150W made by Nitto Denko Co., Ltd.)

Aluminum deposited adhesive tape (FNS KESHI S50 mad by Rintech Co., Ltd.)

5 As shown in Figure 6, the thus fabricated diffuse reflection type hologram 31 having the polarizing plate 27 was located on the backlight side of the liquid crystal display element 20 to thereby obtain a liquid crystal display device which can uniformly diffuse and reflect light incident at an angle of  $20^\circ$  from above within a range defined by an upward angle of about  $20^\circ$ , a downward angle of about  $30^\circ$ , and breadth-wise angles of about  $30^\circ$ , and enables bright color displays to be presented in the light without recourse to any self-luminous type backlight.

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15 While the inventive liquid crystal display device using a hologram has been described with reference to some embodiments, it should be understood that the present invention is in no sense limited to such embodiments, and many other modifications may be possible.

20 The hologram scatter plate according to the present invention is characterized by comprising a transmission type hologram layer and a back side layer, as viewed from an incident side thereof. This hologram scatter plate is broken down into three types depending on where to have scatter  
25 function. As shown schematically in Figure 11, a first type of the hologram scatter plate 53 comprising the transmission hologram layer 51 and the back side surface 52 allows only the transmission hologram layer 51 to have diffusion and

diffraction functions and the back side surface 52 to be provided in the form of a mirror reflection layer (Figure 11(a)); a second type allows the transmission hologram layer 51 to have diffraction function alone and the back side layer 52 to have diffuse reflection function (Figure 11(b)); and a third type allows the transmission type hologram 51 to have diffusion and diffraction functions and the back side layer 52 to have diffuse reflection function (Figure 11(c)). Note that reference numeral 62 represents illumination light.

In either case, a hologram that is of the volume phase yet transmission type is used for the hologram 51, and incident light 62 and light reflected at the back side layer 52 are diffracted through the transmission type hologram 51 in any desired direction.

Referring now to how to make such a transmission type hologram 51 by means of holography, the hologram having diffraction function alone (Figure 11(b)) is recorded on a dry plate 54 formed of photopolymer, etc., for recording a volume phase type hologram by permitting parallel object light 55 to be almost vertically incident on the dry plate 54 and parallel reference light 56 to be incident on the dry plate 54 from a direction corresponding to the direction of illumination light 62 for interference in the dry plate 54, as shown in Figure 12. The hologram having both diffraction function and diffusion function (Figure 11(a), (c)) is recorded on the dry plate 54 formed of photopolymer, etc., for forming a volume phase type hologram by locating a scatter plate 57 in front of the dry plate 54, permitting

illumination light 58 to be incident on the scatter plate 57 to provide light scattered through the scatter plate 57 and directly transmitted light in the form of object light, while permitting parallel light incident from a direction

5 corresponding to illumination light 62 to be incident on the dry plate 54 in the form of reference light 59 for interference purposes, as shown in Figure 13.

10 The back side layer 52 herein used may be of the mirror reflection type wherein a reflecting metal such as aluminum, and silver is deposited on the upper or lower surface of a substrate film by means of evaporation or a metal foil is applied thereon. Alternatively, the back side layer 52 may be of the diffuse reflection type that is composed of a thin, mirror-finished metal plate. For instance, use may be made 15 of a metal or other reflecting substrate subjected to surface matting, etc. to have a fine asperity pattern thereon, a substrate film having a scattering center therein and deposited on its back surface with a reflecting metal by means of evaporation or applied on its back surface with a 20 metal foil, etc., a substrate film treated on one surface to have a fine asperity pattern and deposited on the other surface with a reflecting metal or applied thereon with a metal foil, etc., a photodiffusion film formed of a resin film which is coated or printed on one surface thereof with a 25 photodiffusion ink having at least one fine particle dispersed therein, said at least one fine particle selected from the group consisting of an inorganic bead, an inorganic filler, an organic bead and a hollow bead, a photodiffusion

film formed of a transparent resin in which said at least one fine particle is dispersed, or a known photodiffusion film having a reflecting metal deposited on its back surface by means of evaporation or a metal foil, etc. applied on its back surface.

Examples of the aforesaid substrate film having a scattering center, and the substrate film surface-treated to have a fine asperity pattern thereon are polyethylene (PE) film, uniaxially stretched polyethylene film, biaxially stretched polyethylene film, stretched polypropylene (OPP) film, nonstretched polypropylene (CPP) film, ethylene-vinyl acetate copolymer (EVA) film, ionomer film, ethylene-ethyl acrylate copolymer (EEA) film, ethylene-acrylic acid copolymer (EAA) film, ethylene-methacrylic acid copolymer (EMAA) film, ethylene-methyl methacrylate copolymer (EMMA) film, ethylene-methyl acrylate copolymer (EMA) film, polyester film, nylon film, triacetylcellulose film, ethylene-vinyl alcohol copolymer (EVOH) film, polyvinylidene chloride (PVDC) film, biaxially stretched polyvinylidene chloride film, polyvinylidene fluoride film, polyacrylonitrile (PAN) film, polybutylene terephthalate (PBT) film, polyethylene terephthalate (PET) film, polyethylene terephthalate (PEN) film, amorphous polyethylene terephthalate (A-PET) film, polystyrene film, polyvinyl chloride film, polyvinyl alcohol film, polycarbonate (PC) film, polymethyl methacrylate (PMMA) film, polyurethane film, fluorocarbon resin film, polymethylpentene film, polybutene film, polyimide film, and polyacrylate film. Various co-extruded films may be used as

well. These substrate films must be capable of supporting layer stacks, and so have a thickness of 1  $\mu\text{m}$  to 500  $\mu\text{m}$ , preferably 10  $\mu\text{m}$  to 100  $\mu\text{m}$ .

If required, an adhesive layer may be interleaved

5 between the transmission type hologram layer 51 and the back side layer 52. The adhesive layer may contain adhesives such as elastomer adhesives, for instance, those based on natural rubber, reclaimed rubber, chloroprene rubber, nitrile rubber, styrene-butadiene rubber, and thermoplastic elastomers; 10 synthetic resin adhesives such as those based on epoxy resin, and polyurethane; chemical reaction type adhesives such as those based on reaction type acrylic, and cyano acrylate; UV curable adhesives; EB curable adhesives; ethylene-vinyl acetate copolymer resin hot-melt adhesives; polyamide 15 adhesives; polyester adhesives; thermoplastic elastomer adhesives; hot-melt adhesives such as reactive hot-melt adhesives; aqueous adhesives or water-soluble adhesives; emulsion adhesives; latex adhesives; and inorganic adhesives. For bonding, the thermoplastic adhesives may be cured by 20 heating to a temperature higher than their softening points while they are interleaved between layers forming a stack; the UV and EB curable adhesives may be cured by irradiation with ultraviolet radiation, and electron beams while they are interleaved between layers forming a stack; and the tacky 25 adhesives may be cured as such while they are interleaved between layers forming a stack.

Examples of the three hologram diffuse plates shown in Figure 11 will now be explained.

Example 1 for Hologram Diffuse Plate

A hologram photosensitive material (Omnidex 352 made by Du Pont) was applied on a glass substrate to form a hologram recording dry plate. Using the optical system shown in Figure 13 under the following conditions, hologram recording was carried out.

Laser wavelength: 514.5 nm (argon laser)

Reference light 59: 30° from normal of dry plate 54/  
parallel light

Object light: Vertical incidence of illumination light 58 on scatter plate 57/light transmitted and scattered through scatter plate 57

Exposure: 60 mJ/cm<sup>2</sup> (at an intensity of 1 mW/cm<sup>2</sup>)

Intensity ratio between reference light 59 and object light:  
approximately 1:1

The obtained hologram was irradiated with ultraviolet radiation at 100 mJ/cm<sup>2</sup>, and then heated at 120°C for 2 hours to obtain the transmission type hologram 51. Applied on this hologram 51 was a mirror-finished, aluminum-deposited PET film (Metalumy TS #300 made by Toray Industries, Inc.) in the form of the back side layer 52, with a double-sided adhesive film (MC2000 made by Nitto Denko Co., Ltd.) interleaved between them, thereby obtaining the inventive scatter plate 53 (Figure 11(a)).

Example 2 for Hologram Diffuse Plate

A hologram photosensitive material (Omnidex 352 made by Du Pont) was applied on a glass substrate to form a hologram recording dry plate. Using the optical system shown in



Figure 12 under the following conditions, hologram recording was carried out.

Laser wavelength: 514.5 nm (argon laser)

Reference light 56: 30° from normal of dry plate 54/

5 parallel light

Object light 55: Vertical incidence/parallel light

Exposure: 60 mJ/cm<sup>2</sup> (at an intensity of 1 mW/cm<sup>2</sup>)

Intensity ratio between reference light 56 and object light 55: approximately 1:1

10 The obtained hologram was irradiated with ultraviolet radiation at 100 mJ/cm<sup>2</sup>, and then heated at 120°C for 2 hours to obtain the transmission type hologram 51. Applied on this hologram 51 was a light-scattering back side film (FNS KESHI S50 made by Rintec Co., Ltd.) in the form of the back side layer 52, with a double-sided adhesive film (MC2000 made by Nitto Denko Co., Ltd.) interleaved between them, thereby obtaining the inventive scatter plate 53 (Figure 11(b)).

15 Example 3 for Hologram Diffuse Plate

A hologram photosensitive material (Omnidex 352 made by Du Pont) was applied on a glass substrate to form a hologram recording dry plate. Using the optical system shown in Figure 13 under the following conditions, hologram recording was carried out.

Laser wavelength: 514.5 nm (argon laser)

25 Reference light 59: 30° from normal of dry plate 54/

parallel light

Object light: Vertical incidence of illumination light 58 on scatter plate 57/light transmitted and

scattered through scatter plate 57

Exposure: 60 mJ/cm<sup>2</sup> (at an intensity of 1 mW/cm<sup>2</sup>)

Intensity ratio between reference light 59 and object light:  
approximately 1:1

- 5        The obtained hologram was irradiated with ultraviolet radiation at 100 mJ/cm<sup>2</sup>, and then heated at 120°C for 2 hours to obtain the transmission type hologram 51. Applied on this hologram 51 was a light-scattering back side film (FNS KESHI S50 made by Rintec Co., Ltd.) in the form of the back side layer 52, with a double-sided adhesive film (MC2000 made by Nitto Denko Co., Ltd.) interleaved between them, thereby obtaining the inventive scatter plate 53 (Figure 11(c)).

Example 4 for Hologram Diffuse Plate

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15  
A hologram photosensitive material (Omnidex 352 made by Du Pont) was applied on a glass substrate to form a hologram recording dry plate. Using the optical system shown in Figure 13 under the following three sets of conditions, hologram recording was carried out.

- First set of conditions -

- 20    Laser wavelength: 488 nm (argon laser)

Reference light 59: 30° from normal of dry plate 54/  
parallel light

Object light: Vertical incidence of illumination light 58 on  
scatter plate 57/light transmitted and

- 25        scattered through scatter plate 57

Exposure: 60 mJ/cm<sup>2</sup> (at an intensity of 1 mW/cm<sup>2</sup>)

Intensity ratio between reference light 59 and object light:  
approximately 1:1

- Second set of conditions -

Laser wavelength: 550 nm (dye laser)

Reference light 59: 30° from normal of dry plate 54/  
parallel light

- 5 Object light: Vertical incidence of illumination light 58 on  
scatter plate 57/light transmitted and  
scattered through scatter plate 57

Exposure: 60 mJ/cm<sup>2</sup> (at an intensity of 1 mW/cm<sup>2</sup>)

Intensity ratio between reference light 59 and object light:  
approximately 1:1

- Third set of conditions -

Laser wavelength: 647 nm (krypton laser)

Reference light 59: 30° from normal of dry plate 54/  
parallel light

- 15 Object light: Vertical incidence of illumination light 58 on  
scatter plate 57/light transmitted and  
scattered through scatter plate 57

Exposure: 60 mJ/cm<sup>2</sup> (at an intensity of 1 mW/cm<sup>2</sup>)

Intensity ratio between reference light 59 and object light:  
20 approximately 1:1

Each of the thus obtained holograms was irradiated with  
ultraviolet radiation at 100 mJ/cm<sup>2</sup>, and then heated at 120°C  
for 2 hours to obtain a transmission type hologram. Three  
such holograms were stacked together with double-sided  
25 adhesive films (MC2000 made by Nitto Denko Co., Ltd.)  
interleaved between them. Applied on the backmost side of  
the stack was a light scattering back side film (FNS KESHI  
S50 made by Rintech Co., Ltd.) in the form of the back side

layer 52, with a double-sided adhesive film (MC2000 made by Nitto Denko Co., Ltd.) interleaved between them, thereby obtaining the inventive scatter plate 53 (Figure 11(c)).

While the hologram scatter plate according to this invention has been described with reference to some examples, it should be understood that the invention is never limited to these examples whatsoever, and so many other modifications may be possible.

A hologram, when used with a large liquid crystal display or a projector screen, must have a large area. To fabricate a large-area diffuse reflection type hologram, hologram plates must be joined together with joints recorded therein.

So far, a diffuse reflection type hologram has been fabricated by superposing a photosensitive material film on a surface of a plane plate form of diffuse reflection hologram backed with a light absorbing layer, stacking a protective glass on the photosensitive material film, and permitting laser light to be incident on the whole assembly from the protective glass so that the incident light, and light reflected and diffracted from the plate can interfere with each other in the photosensitive material film to thereby replicate the plate, as shown in Figure 19(a), or winding a film form of diffuse reflection hologram backed with a light absorbing layer around a cylinder, winding a photosensitive material film around the hologram film in contact relation thereto, with an index matching liquid contained between them, and permitting laser light to be incident on a part of

the hologram film such that it can cross the photosensitive material film at a position where the photosensitive material film comes into close contact with the hologram film, while rotating the cylinder in a direction shown by an arrow,

5 whereby the incident light, and light reflected and diffracted from the hologram film can be made to interfere successively with each other to make the hologram film by replication, as shown in Figure 19(b).

10 In the process shown in Figure 19(a), however, the size of the diffuse reflection type hologram to be fabricated is limited to the size of the hologram plate used; that is, to fabricate a large-area diffuse reflection type hologram there is no option all but to join together a plurality of holograms. With the process shown in Figure 19(b), a  
15 continuous diffuse reflection type hologram having a large area may be fabricated because the hologram film wound around the cylinder has joints therein. However, such joints remain recorded in the replicated hologram film.

20 In what follows, the inventive process of replicating a diffuse reflection type hologram used with liquid crystal display devices, etc. will be explained with reference to a specific embodiment.

*Just add*  
25 Figure 14 illustrates one exemplary layout for carrying out the replication process according to the present invention, and Figure 15 shows how to assemble a hologram plate support used in carrying out the same. In the present invention, a plate form of diffuse reflection hologram 61 to be replicated is applied, in striped forms, on the surface of

[illegible]

An absorbing glass 68 is applied on the plane back side of the semicylindrical transparent member 62, with an adhesive layer 67 interleaved between them, for the purpose of preventing interference of the incident light with reflected light obtained by internal reflection at this plane of laser light 66 transmitted through the hologram plate 61, which may otherwise cause unnecessary interference fringes to

be recorded. Instead of this, an absorbing layer may be provided on the back side of the hologram plate 61.

To apply the hologram plate 61 on the semicylindrical surface of the semicylindrical transparent member 62, an absorbing glass 68 is applied on the back side of the semicylindrical transparent member 62, as shown in Figure 15(a). Alternatively, a rectangular recording film 61' is previously made, which has the hologram plate 61 recorded on a transversally striped middle region thereof and has a width smaller than the length of the transparent member 62, as shown in Figure 15(b). Then, this recording film 61' may be applied on the semicylindrical surface of the semicylindrical transparent member 62, as shown in Figure 15(c). In the layout shown in Figure 14, it is to be noted that the axis (generating line) of the semicylindrical transparent member 62 may be directed either horizontally or vertically.

Available for the fabrication of the diffuse reflection type hologram 61 are some methods, two of which are shown; Figure 16 illustrates a single-step holography method and Figure 17 depicts a two-step holography method. According to the single-step holography method shown in Figure 16, a reflection type of hologram dry plate 71 formed of photopolymer as an example (a Lippmann hologram dry plate) is located at a predetermined diffuse reflection region with respect to a scatter plate 70 formed typically of frosted glass. The scatter plate 70 is illuminated from its back side with one coherent light 72 of given wavelength obtained by halving light emanating from the same light source so that

scattered light 74 or object light leaving the front side of the scatter plate 70 can be incident on the reflection type of hologram dry plate 71. At the same time, another coherent light 73 of given wavelength emanating from the same light source or reference light is incident on the opposite side of the dry plate 71, said reference light propagating opposite to light assumed to be incident on the diffuse reflection type hologram plate 61, so that the diffuse reflection type hologram plate 61 can be recorded on the reflection type of hologram dry plate 71.

According to the two-step holography method shown in Figure 17, a transmission type of hologram dry plate 75 is located at a predetermined diffuse reflection region with respect to a scatter plate 70 formed typically of frosted glass, as shown in Figure 17(a). The scatter plate 70 is illuminated from its back side with one coherent light 72 of given wavelength obtained by halving light emanating from the same light source, so that scattered light 74 leaving the front side of the scatter plate 70 or object light can be incident on the transmission type of hologram dry plate 75. At the same time, another coherent light 76 of given wavelength emanating from the same light source or reference light is incident on the same side of the dry plate 75 at any desired angle, so that a first or transmission type hologram can be recorded on the transmission type of hologram dry plate 75.

Then, this first hologram, shown at 77 in Figure 17(c), is located at the position of the former transmission type of

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hologram dry plate 75, and a reflection type of hologram dry plate 80 is now located at the position of the scatter plate 70. The hologram 77 is irradiated with reconstructing illumination light 78 that is opposite in the direction of propagation to, and the same in wavelength as, the recording reference light 76 such that a real image of the hologram 77 can be formed at a position of the reflection type of hologram dry plate 80 (corresponding to the position of the scatter plate 70 shown in Figure 17(a)), whereupon diffracted light 79 from the hologram 77 or object light is incident on the reflection type of hologram dry plate 80. At the same time, reference light 81 that propagates opposite to incident light assumed for the diffuse reflection type hologram 61 is incident on the opposite side of the reflection type of hologram dry plate 80, whereby a second or diffuse reflection type of hologram plate is recorded on the reflection type of hologram dry plate 80. In this way, it is possible to fabricate the diffuse reflection type hologram plate 61 with a viewing region limited to the range of the first hologram 77.

It is here to be noted that instead of the thus fabricated hologram plate 61, a hologram plate fabricated from the same by contact replication, too, may be used.

One illustrative example of the inventive replicating process will be explained. An adhesive layer 67 formed of U-471 made by Kyoritsu Kagaku Co., Ltd. was applied on a semi-cylindrical glass block 62, using NG4 made by Shot Co., Ltd. as an absorbing glass 68. Then, a hologram plate 61 was

fixed on the glass block 62 with an index matching liquid made of xylene contained between them. The hologram plate 61 used was optically characterized in that light incident upwardly on the recording surface at an angle of incidence of 20° with respect to the normal line thereof can be diffused and reflected within a range defined by an upward angle of 20°, a downward angle of 20° and breadth-wise angles of 30° with respect to the normal line. While a roll form of photosensitive material film 63 was slid on the surface of the hologram plate 61 applied on the semicylindrical glass block 62, using an index matching liquid again formed of xylene as lubricant, the hologram plate 61 was irradiated through the roll form of photosensitive material film 63 with laser light 66 controlled by a cylindrical lens such that it diverges only in the generating direction of the glass block 62, whereby the laser light, and diffracted light from the hologram plate 61 could be made to interfere with each other to achieve continuous recording of the diffuse reflection type hologram on the photosensitive material film 63.

The inventive diffuse reflection type hologram replication process has been described with reference to some examples, it should be understood that the present invention is by no means limited to such examples at all, and so many other modifications may be made.

As can be seen from the foregoing explanations, according to the first inventive liquid crystal display device using a hologram wherein on a display surface side of a liquid crystal display element or between a liquid crystal

display element and a backlight there is provided a diffuse transmission type hologram capable of diffusing and transmitting light incident from a specific direction only in a direction defined as a viewing region, it is possible to make wide a visual field region where displayed images can be observed and reduce luminance drops, so that bright displayed images can be presented. It is here to be noted that the present invention may be modified such that the visual field range can be arbitrarily set to observe images only in a plurality of different directions, and it is not always required to locate a scatter plate on the backlight side.

According to the second inventive liquid crystal display device using a hologram wherein on a back surface side of a liquid crystal display element opposite to a display surface side thereof there is provided a diffuse reflection type hologram capable of diffusing and reflecting light incident from a specific direction only in a direction defined as a viewing region as mentioned above, it is possible to present bright displays in the light without recourse to any self-luminous type backlight.

According to the inventive hologram scatter plate wherein a transmission type hologram layer and a back side layer are stacked together in the described order, it is possible to limit the direction of diffraction and scattering by means of the transmission hologram and increase reflectance over a wide wavelength region by means of the back side layer, so that diffused light having high luminance can be obtained over a wide wavelength and viewing angle

range, so making bright displays, etc. possible. It is here to be noted that the transmission type hologram layer, if it has diffraction function, or diffusion function and diffraction function, with respect to a plurality of different wavelengths, especially, three wavelengths in R, G and B regions, can then present displays brighter (three times as bright on calculation) than those obtained with a hologram layer having diffraction function, or diffusion function and diffraction function, with respect to a single wavelength.

According to the inventive diffuse reflection type hologram replication process wherein while a photosensitive material film is slid on a fixed diffuse type hologram plate in contact relation thereto, the hologram plate is irradiated from the photosensitive material film with a light beam of linear section that becomes wide in a widthwise direction of the film, so that a diffuse reflection type hologram can be continuously recorded in the photosensitive material film by interference of the incident light beam with a light beam reflected and diffracted by the diffuse reflection type hologram plate, it is possible to easily fabricate, with no need of using any large hologram plate, a large yet continuous film form of diffuse reflection type hologram having neither joints nor recorded joints therein, which has high reflectance and quality, and so is best suited for use with backlights, projector screens, combiners, etc. for liquid crystal display devices.